Mingmei Wang

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Education

PhD, Chemical Engineering, Iowa State University, Ames, Iowa, 2006~present

Supervisor: Prof. Mark J. Kushner E-mail: mjkush@umich.edu

- M. E., Applied Chemistry, University of Science and Technology Beijing, Beijing, P.R.China, 2006
- B. E., Fine Chemical Engineering, Tianjin University, Tianjin, P. R. China, 2000

Research and Professional Experience

1. PhD. Research (Aug. 2006-present)

Optical and Discharge Physics Lab, Iowa State University, Ames, Iowa (Currently, Institute for Plasma Science and Engineering, University of Michigan, Ann Arbor, MI)

- Simulation of plasma etching of high aspect ratio semiconductor features.
- Chemical and physical mechanisms for surface and bulk interactions in both gas and solid phases.
- ◆ Code development on modeling profile and electric field evolution during etching.
- Research on eliminating profile twisting (due to charging) and bowing (due to mask effects) during microelectronics fabrication.
- ♦ High energy electron beam effects on elimination of twisting and angle control in nano-scale features.
- ♦ Modeling of mixing layer damage during low-k material etching.
- Preprocessing of multi-layer or single layer mask to optimize feature profile and etch rate.

2. M. E. Research (Sep. 2003 – Mar. 2006):

Laboratory of Separation Science and Engineering, State Key Laboratory of Biochemical Engineering, Institute of Process Engineering, Chinese Academy of Sciences, Beijing, China

Thesis Title: Study of Stable Foam System for Decontamination and Interface Phenomena

(Research Fellowship: National Natural Science Foundation of China)

- Testing of foam stability and foamability of surfactants.
- Influence of active decontaminating substance on foam characteristics.
- Studies on foam rupture mechanisms and optimization of surfactants.

3. Professional Experience (Aug. 2000 - Aug. 2003):

Research Engineer, Tianjin Power Source Institute, Tianjin, China

- Design of Li-ion battery with high specific capacity.
- Monitoring of electric performance of batteries.

Publications

1. Journal Articles:

- **M. Wang** and M. J. Kushner. High Energy Electron Beams in Capacitively Coupled Plasmas I: Fundamental Characteristics. In preparation.
- M. Wang and M. J. Kushner. High Energy Electron Beams in Capacitively Coupled Plasmas II: Effects on Twisting in High Aspect Ratio Etching of Dielectrics. In preparation.
- M. Wang, Z.D. Chang, H.L. Xi, Y.J. Zuo, H.Z. Liu and W.J. Li. Advances in Measurement Techniques and Influence Factors on Aqueous Foam Stability. *Chemical Industry and Engineering Progress*, 2005, 24 (7): 723-728. (In Chinese).

2. Conference Proceedings and Presentations:

- **Mingmei Wang** and Mark J. Kushner. Consequences of Implanting and Surface Mixing During Si and SiO₂ Plasma Etching. *36th ICOPS*. (Oral presentation) San Diego, CA, June 2009.
- Mingmei Wang and Mark J. Kushner. Aspect Ratio Dependent Twisting and Mask Effects During Plasma Etching of SiO2 in Fluorocarbon Gas Mixture, *AVS 55th International Symposium and Exhibition*. (Poster) Boston, MA, October 2008.
- Mingmei Wang and Mark J. Kushner. Effects of Charging and Mask Erosion in SiO2 High Aspect Ratio Etching in Fluorocarbon Plasmas, *TECHCON 2008*. (Oral and poster presentation) Austin, TX, November 2008.
- Mingmei Wang and Mark J. Kushner. Numerical Investigations for Eliminating Charging Effects on twisting of High Aspect Ratio Features During SiO2 Etching in Fluorocarbon Plasmas, *Gordon Research Conference 2008*. (Poster) South Hadley, MA, July 2008.
- Mingmei Wang, Ankur Agarwal, Yang Yang and Mark J. Kushner. Plasma Etching of Extremely High Aspect Ratio Features: Twisting Effects, *60th Gaseous Electronics Conference* (Oct. 2007). (Poster) Washington, DC, October 2007.
- Yang Yang, **Mingmei Wang** and Mark J. Kushner. "Progress, Opportunities and Challenges in Modeling of Plasma Etching", *11th International Interconnect Technology Conference*, Burlingame, CA, June 2008.
- Mingmei Wang, Zhidong Chang et al. Effect of the Surfactant on the Production and Stability of Aqueous Decontamination Foams, *International Solvent Extraction Conference 2005 (ISEC2005)*, (Oral presentation) Beijing, China, September 2005.